AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions and listings of claims in the application:

1-64 (Cancelled)

65. (Currently Amended) A lip makeup composition comprising at least one cosmetically acceptable organic liquid medium and at least one styrene-free film-forming linear block ethylenic polymer, wherein the lip makeup composition has a resistive index of greater than or equal to 80%,

and further wherein the at least one styrene-free film-forming linear block ethylenic polymer has a polydispersity index of greater than [[2]]2.5 and comprises ~~at least one~~ a first block and ~~at least one~~ a second block, wherein the ~~at least one~~ first block and the ~~at least one~~ second block are connected together via ~~at least one~~ an intermediate block comprising at least one constituent monomer of the ~~at least one~~ first block and at least one constituent monomer of the ~~at least one~~ second block, wherein the at least one constituent monomer of the first block differs from the at least one constituent monomer of the second block, said ~~at least one~~ intermediate block is a random copolymer block with a Tg that ranges from the glass transition temperature of the first block to the glass transition temperature of the second block, and the ~~at least one~~ first block is chosen from:

a) a block with a Tg of greater than or equal to 40°C,

b) a block with a Tg of less than or equal to 20°C,

c) a block with a Tg from greater than 20 to less than 40°C,

and the ~~at least one~~ second block is chosen from a category a), b) or c) different from the ~~at least one~~ first block.

66. (Currently Amended) A lip makeup composition comprising at least one cosmetically acceptable organic liquid medium and at least one non-elastomeric film-forming linear block ethylenic polymer, wherein the lip makeup composition has a resistive index of greater than or equal to 80%,

and further wherein the at least one non-elastomeric film-forming linear block ethylenic polymer has a polydispersity index of greater than [[2]] or equal to 2.5 and comprises ~~at least one~~ a first block and ~~at least one~~ a second block, wherein the ~~at least one~~ first block and the ~~at least one~~ second block are connected together via ~~at least one~~ an intermediate block comprising at least one constituent monomer of the ~~at least one~~ first block and at least one constituent monomer of the ~~at least one~~ second block, wherein the at least one constituent monomer of the first block differs from the at least one constituent monomer of the second block, said ~~at least one~~ intermediate block is a random copolymer block with a Tg that ranges from the glass transition temperature of the first block to the glass transition temperature of the second block, and the ~~at least one~~ first block is chosen from:

a) a block with a Tg of greater than or equal to 40°C,

b) a block with a Tg of less than or equal to 20°C,

c) a block with a Tg from greater than 20 to less than 40°C,

and the ~~at least one~~ second block is chosen from a category a), b) or c) different from the ~~at least one~~ first block.

67. (Previously Presented) The lip makeup composition according to Claim 65 wherein the lip makeup composition has a resistive index of greater than or equal to 85%.

68. (Previously Presented) The lip makeup composition according to Claim 67, wherein the lip makeup composition has a resistive index of greater than or equal to 95%.

69. (Previously Presented) The lip makeup composition according to Claim 65 wherein the at least one block ethylenic polymer is not soluble at a content of at least 1% by weight in water or in a mixture of water and of linear or branched lower monoalcohols containing from 2 to 5 carbon atoms, without pH modification, at room temperature (25°C).

70. (Cancelled)

71. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ first block and the ~~at least~~ second block are such that the difference between the glass transition temperatures (Tg) of the ~~at least one~~ first block and the ~~at least one~~ second block is greater than 10°C.

72. (Currently Amended) The lip makeup composition according to Claim 71, wherein the ~~at least one~~ first block and the ~~at least~~ second block are such that the difference between the glass transition temperatures (Tg) of the ~~at least one~~ first block and the ~~at least one~~ second block is greater than 40°C.

73. (Cancelled)

74. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ first block and the ~~at least one~~ second block of the at least one block ethylenic polymer are mutually incompatible.

75. (Cancelled)

76. (Previously Presented) The lip makeup composition according to Claim 65, wherein the at least one block ethylenic polymer has a polydispersity index ranging from 2.8 to 6.

77. (Cancelled)

78. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one block ethylenic polymer comprises at least one~~ first block has [[with]] a glass transition temperature (Tg) of greater than or equal to 40°C and the ~~at least one~~ second block with a glass transition temperature of less than or equal to 20°C.

79. (Currently Amended) The lip makeup composition according to Claim 78, wherein the proportion of the ~~at least one~~ first block ranges from 20% to 90% by weight of the at least one block ethylenic polymer.

80. (Currently Amended) The lip makeup composition according to Claim 79, wherein the proportion of the ~~at least one~~ first block ranges from 50% to 70% by weight of the at least one block ethylenic polymer.

81. (Currently Amended) The lip makeup composition according to Claim 78, wherein the proportion of the ~~at least one~~ second block with a Tg of less than or equal to 20°C ranges from 5% to 75% by weight of the at least one block ethylenic polymer.

82. (Currently Amended) The lip makeup composition according to Claim 81, wherein the proportion of the ~~at least one~~ second block with a Tg of less than or equal to 20°C ranges from 25% to 45% by weight of the at least one block ethylenic polymer.

83. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one block polymer comprises at least one~~ first block has [[with]] a glass transition temperature (Tg) of between 20 and 40°C and ~~at least one~~ the second block has [[with]] a glass transition temperature of less than or equal to 20°C or a glass transition temperature of greater than or equal to 40°C.

84. (Currently Amended) The lip makeup composition according to Claim 83, wherein the proportion of the ~~at least one~~ first block with a Tg of between 20 and 40°C ranges from 10% to 85% by weight of the at least one block ethylenic polymer.

85. (Currently Amended) The lip makeup composition according to Claim 84, wherein the proportion of the ~~at least one~~ first block with a Tg of between 20 and 40°C ranges from 50% to 70% by weight of the at least one block ethylenic polymer.

86. (Currently Amended) The lip makeup composition according to Claim 83, wherein the ~~at least one~~ second block has a Tg of greater than or equal to 40°C.

87. (Currently Amended) The lip makeup composition according to Claim 83, wherein the proportion of the ~~at least one~~ second block with a Tg of greater than or equal to 40°C ranges from 10% to 85% by weight of the at least one block ethylenic polymer.

88. (Currently Amended) The lip makeup composition according to Claim 87, wherein the proportion of the ~~at least one~~ second block with a Tg of greater than or

equal to 40°C ranges from 30% to 70% by weight of the at least one film-forming linear block ethylenic polymer.

89. (Currently Amended) The lip makeup composition according to Claim 83, wherein the ~~at least one~~ second block has a Tg of less than or equal to 20°C.

90. (Currently Amended) The lip makeup composition according to Claim 65, wherein the proportion of the ~~at least one~~ block with a glass transition temperature of less than or equal to 20°C ranges from 20% to 90% by weight of the at least one block ethylenic polymer.

91. (Currently Amended) The lip makeup composition according to Claim 90, wherein the proportion of the ~~at least one~~ block with a glass transition temperature of less than or equal to 20°C ranges from 50% to 70% by weight of the at least one block ethylenic polymer.

92. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ block with a Tg of greater than or equal to 40°C is totally or partially derived from at least one monomer whose homopolymer has a glass transition temperature of greater than or equal to 40°C.

93. (Currently Amended) The lip makeup composition according to Claim 92, wherein the ~~at least one~~ block with a Tg of greater than or equal to 40°C is totally or partially derived from at least one monomer whose homopolymer has a glass transition temperature ranging from 60°C to 120°C.

94. (Currently Amended) The lip makeup composition according to Claim 92, wherein the ~~at least one~~ block with a Tg of greater than or equal to 40°C is a copolymer

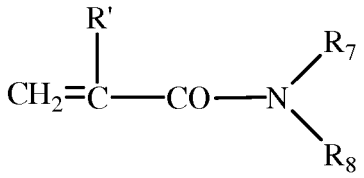
derived from at least one monomer whose homopolymer has a glass transition temperature of greater than or equal to 40°C.

95. (Previously Presented) The lip makeup composition according to Claim 92, wherein the at least one monomer whose homopolymer has a glass transition temperature of greater than or equal to 40°C is chosen from the following monomers:

- methacrylates of formula $CH_2 = C(CH_3)\text{-}COOR_1$ in which R_1 is a C_1 to C_4 linear or branched unsubstituted alkyl group or R_1 is a C_4 to C_{12} cycloalkyl group,
- acrylates of formula $CH_2 = CH\text{-}COOR_2$

in which R_2 is a C_4 to C_{12} cycloalkyl group and

- (meth)acrylamides of formula:



in which R_7 and R_8, which may be identical or different, are chosen from hydrogen atoms and C_1 to C_{12} linear or branched alkyl groups; or R_7 is hydrogen and R_8 is a 1,1-dimethyl-3-oxobutyl group, and R' is chosen from hydrogen and methyl.

96. (Previously Presented) The lip makeup composition according to Claim 92, wherein the at least one monomer whose homopolymer has a glass transition temperature of greater than or equal to 40°C is chosen from methyl methacrylate, isobutyl methacrylate and isobornyl (meth)acrylate.

97. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ block with a Tg of greater than or equal to 40°C is a homopolymer.

98. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ block with a Tg of less than or equal to 20°C is totally or partially derived from at least one monomer whose homopolymer has a glass transition temperature of less than or equal to 20°C.

99. (Currently Amended) The lip makeup composition according to Claim 98, wherein the ~~at least one~~ block with a Tg of less than or equal to 20°C is totally or partially derived from at least one monomer whose homopolymer has a glass transition temperature ranging from -50°C to 0°C.

100. (Previously Presented) The lip makeup composition according to Claim 98, wherein the at least one monomer whose homopolymer has a glass transition temperature of less than or equal to 20°C is chosen from the following monomers:

- acrylates of formula $CH_2 = CHCOOR_3$, wherein

R_3 is a linear or branched C_1 to C_{12} unsubstituted alkyl group, with the exception of the tert-butyl group, in which at least one hetero atom chosen from O, N and S is optionally intercalated;

- methacrylates of formula $CH_2 = C(CH_3)\text{-}COOR_4$, R_4 is a linear or branched C_6 to C_{12} unsubstituted alkyl group, in which at least one hetero atom chosen from O, N and S is optionally intercalated;

- vinyl esters of formula $R_5\text{-}CO\text{-}O\text{-}CH = CH_2$

in which R_5 is a linear or branched C_4 to C_{12} alkyl group,

- C_4 to C_{12} alkyl vinyl ethers; and
- N-(C_4 to C_{12}) alkyl acrylamides.

101. (Previously Presented) The lip makeup composition according to Claim 98, wherein the at least one monomer whose homopolymer has a glass transition

temperature of less than or equal to 20°C is chosen from alkyl acrylates whose alkyl chain contains from 1 to 10 carbon atoms, with the exception of the tert-butyl group.

102. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ block with a glass transition temperature of less than or equal to 20°C is a homopolymer.

103. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ block with a Tg from greater than 20°C to less than 40°C is totally or partially derived from at least one monomer whose homopolymer has a glass transition temperature ranging from 20°C to 40°C.

104. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ block with a Tg from greater than 20°C to less than and 40°C is a homopolymer of a monomer chosen from n-butyl methacrylate, cyclodecyl acrylate, neopentyl acrylate arid isodecylacrylamide.

105. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ block with a Tg ranging from greater than 20°C to less than 40° is a copolymer totally or partially derived from:

- at least one monomer whose homopolymer has a Tg of greater than or equal to 40°C; and
- at least one monomer whose homopolymer has a Tg of less than or equal to 20°C.

106. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ block with a Tg ranging from greater than 20°C to less than 40°C is totally or partially derived from at least one monomer chosen from methyl

methacrylate, isobornyl (meth) acrylate, trifluoroethyl methacrylate, butyl acrylate and 2-ethylhexyl acrylate.

107. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ first block and/or the ~~at least one~~ second block comprise(s) at least one additional monomer.

108. (Previously Presented) The lip makeup composition according to Claim 107, wherein the at least one additional monomer is chosen from hydrophilic monomers, and monomers containing ethylenic unsaturation comprising one or more silicon atoms.

109. (Previously Presented) The lip makeup composition according to Claim 107, wherein the at least one additional monomer is chosen from:

- ethylenically unsaturated monomers comprising at least one carboxylic or sulfonic acid function,

- methacrylates of formula $CH_2 = C(CH_3)\text{-}COOR_6$

in which R_6 is a linear or branched C_1 to C_4 alkyl group, the said alkyl group being substituted with at least one substituent chosen from hydroxyl groups and halogen atoms,

- methacrylates of formula $CH_2 = C(CH_3)\text{-}COOR_9$,

in which R_9 is a linear or branched C_6 to C_{12} alkyl group in which at least one hetero atoms chosen from O, N and S is (are) optionally intercalated, the said alkyl group being substituted with at least one substituent chosen from hydroxyl groups and halogen atoms;

- acrylates of formula $CH_2 = CHCOOR_{10}$,

in which R_{10} is a linear or branched C_1 to C_{12} alkyl group substituted with at least one substituent chosen from hydroxyl groups and halogen atoms, or

R_{10} is a C_1 to C_{12} alkyl-O-POE (polyoxyethylene) with repetition of the oxyethylene unit 5 to 30 times, or

R_{10} is a polyoxyethylenated group comprising from 5 to 30 ethylene oxide units; and

- ethylenically unsaturated monomers comprising at least one tertiary amine function.

110. (Previously Presented) The lip makeup composition according to Claim 107, wherein the at least one additional monomer is chosen from acrylic acid, methacrylic acid and trifluoroethyl methacrylate.

111. (Currently Amended) The lip makeup composition according to Claim 107, wherein the at least one additional monomer is present in an amount ranging from 1% to 30% by weight relative to the total weight ~~at least one block ethylenic polymer~~of the first block and/or the second block.

112. (Currently Amended) The lip makeup composition according to Claim 65, wherein the ~~at least one~~ first block and the ~~at least one~~ second block comprise at least one monomer chosen from (meth)acrylic acid esters, and optionally at least one monomer chosen from (meth)acrylic acid~~, and mixtures thereof~~.

113. (Currently Amended) The lip makeup composition according to Claim 65, wherein each of the ~~at least one~~ first block and the ~~at least one~~ second block is totally derived from at least one monomer chosen from (meth)acrylic acid esters, and

optionally from at least one monomer chosen from (meth)acrylic acid~~, and mixtures thereof~~.

114. (Previously Presented) The lip makeup composition according to Claim 66, wherein the at least one block polymer is styrene-free.

115. (Previously Presented) The lip makeup composition according to Claim 65, wherein the at least one block ethylenic polymer has a weight-average mass (Mw) of less than or equal to 300,000.

116. (Previously Presented) The lip makeup composition according to Claim 115, wherein the at least one block ethylenic polymer has a weight-average mass (Mw) ranging from 45,000 to 150,000.

117. (Previously Presented) The lip makeup composition according to Claim 65, wherein the at least one block ethylenic polymer has a number-average mass (Mn) of less than or equal to 70,000.

118. (Previously Presented) The lip makeup composition according to Claim 117, wherein the at least one block ethylenic polymer has a number-average mass (Mn) ranging from 12,000 to 50,000.

119. (Previously Presented) The lip makeup composition according to Claim 65, wherein the at least one block ethylenic polymer is not an elastomer.

120. (Previously Presented) The lip makeup composition according to Claim 65, wherein the at least one block ethylenic polymer is present in an amount ranging from 0.1% to 60% by weight relative to the total weight of the composition.

121. (Previously Presented) The lip makeup composition according to Claim 120, wherein the at least one block ethylenic polymer is present in an amount ranging from 1% to 40% by weight relative to the total weight of the composition.

122. (Previously Presented) The lip makeup composition according to Claim 65, further comprising at least one volatile oil.

123. (Previously Presented) The lip makeup composition according to Claim 122, wherein the at least one volatile oil is chosen from octamethylcyclotetrasiloxane, decamethylcyclopentasiloxane, dodecamethylcyclohexasiloxane, heptamethylhexyltrisiloxane, heptamethyloctyltrisiloxane, octamethyltrisiloxane, decamethyltetrasiloxane, isododecane, isodecane and isohexadecane.

124. (Previously Presented) The lip makeup composition according to Claim 122, wherein the at least one volatile oil is present in an amount ranging from 1% to 70% by weight relative to the total weight of the composition.

125. (Previously Presented) The lip makeup composition according to Claim 124, wherein the at least one volatile oil is present in an amount ranging from 10% to 35% by weight relative to the total weight of the composition.

126. (Previously Presented) The lip makeup composition according to Claim 65, further comprising a non-volatile oil.

127. (Previously Presented) The lip makeup composition according to Claim 126, wherein the non-volatile oil is chosen from hydrocarbon-based non-volatile oils and silicone non-volatile oils.

128. (Previously Presented) The lip makeup composition according to Claim 126, wherein the non-volatile oil is present in an amount ranging from 1% to 80% by weight relative to the total weight of the composition.

129. (Previously Presented) The lip makeup composition according to Claim 128, wherein the non-volatile oil is present in an amount ranging from 20% to 50% by weight relative to the total weight of the composition.

130. (Previously Presented) The lip makeup composition according to Claim 65, further comprising at least one fatty substance that is solid at room temperature and chosen from waxes, pasty fatty substances and gums.

131. (Previously Presented) The lip makeup composition according to Claim 65, wherein the lip makeup composition further comprises from 0.1% to 50% by weight of waxes relative to the total weight of the composition.

132. (Previously Presented) The lip makeup composition according to Claim 131, wherein the lip makeup composition further comprises from 1% to 30% of waxes by weight relative to the total weight of the composition.

133. (Previously Presented) The lip makeup composition according to Claim 65, further comprising at least one dyestuff.

134. (Previously Presented) The lip makeup composition according to Claim 65, further comprising at least one cosmetic ingredient chosen from additional film-forming polymers, vitamins, thickeners, trace elements, softeners, sequestering agents, fragrances, acidifying and basifying agents, preserving agents, sunscreens, surfactants and antioxidants.

135. (Previously Presented) The lip makeup composition according to Claim 65, wherein the lip makeup composition is in the form of a paste or a stick.

136. (Previously Presented) The lip makeup composition according to Claim 65, wherein the lip makeup composition is in anhydrous form.

137. (Withdrawn - Currently Amended) A cosmetic assembly comprising:

a) at least one container delimiting at least one compartment, the at least one container being closed by a closing member; and

b) a lip makeup composition placed inside the at least one compartment, wherein the lip makeup composition comprises:

at least one cosmetically acceptable organic liquid medium, and

at least one styrene-free film-forming linear block ethylenic polymer,

wherein the lip makeup composition has a resistive index of greater than or equal to 80%,

and further wherein the at least one styrene-free film-forming linear block ethylenic polymer has a polydispersity index of greater than [[2]] or equal to 2.5 and comprises ~~at least one~~ a first block and ~~at least one~~ a second block, wherein the ~~at least one~~ first block and the ~~at least one~~ second block are connected together via ~~at least one~~ an intermediate block comprising at least one constituent monomer of the ~~at least one~~ first block and at least one constituent monomer of the ~~at least one~~ second block, wherein the at least one constituent monomer of the first block differs from the at least one constituent monomer of the second block, said ~~at least one~~ intermediate block is a random copolymer block with a Tg that ranges from the glass transition temperature of

the first block to the glass transition temperature of the second block, and the ~~at least one~~ first block is chosen from:

a) a block with a Tg of greater than or equal to 40°C,

b) a block with a Tg of less than or equal to 20°C,

c) a block with a Tg from greater than 20 to less than 40°C,

and the ~~at least one~~ second block is chosen from a category a), b) or c) different from the ~~at least one~~ first block.

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138. (Withdrawn - Currently Amended) A cosmetic assembly comprising:

a) at least one container delimiting at least one compartment, the at least one container being closed by a closing member; and

b) a lip makeup composition placed inside the at least one compartment, wherein the lip makeup composition comprises:

at least one cosmetically acceptable organic liquid medium, and

at least one non-elastomeric film-forming linear block ethylenic polymer,

wherein the lip makeup composition has a resistive index of greater than or equal to 80%,

and further wherein the at least one non-elastomeric film-forming linear block ethylenic polymer has a polydispersity index of greater than [[2]] or equal to 2.5 and comprises ~~at least one~~ a first block and ~~at least one~~ a second block, wherein the ~~at least one~~ first block and the ~~at least one~~ second block are connected together via ~~at least one~~ an intermediate block comprising at least one constituent monomer of the ~~at least one~~ first block and at least one constituent monomer of the ~~at least one~~ second block,

wherein the at least one constituent monomer of the first block differs from the at least one constituent monomer of the second block, said ~~at least one~~ intermediate block is a random copolymer block with a Tg that ranges from the glass transition temperature of the first block to the glass transition temperature of the second block, and the ~~at least one~~ first block is chosen from:

a) a block with a Tg of greater than or equal to 40°C,

b) a block with a Tg of less than or equal to 20°C,

c) a block with a Tg from greater than 20 to less than 40°C,

and the ~~at least one~~ second block is chosen from a category a), b) or c) different from the ~~at least one~~ first block.

139. (Withdrawn - Previously Presented) The cosmetic assembly according to Claim 137, wherein the at least one container is at least partially formed from at least one thermoplastic material.

140. (Withdrawn - Previously Presented) The cosmetic assembly according to Claim 137, wherein the at least one container is at least partially formed from at least one non-thermoplastic material.

141. (Withdrawn - Previously Presented) The cosmetic assembly according to Claim 137, wherein in the closed position of the at least one container, the closing member is screwed onto the container.

142. (Withdrawn - Previously Presented) The cosmetic assembly according to Claim 137, wherein in the closed position of the at least one container, the closing member is coupled to the at least one container by click-fastening, bonding or welding.

143. (Withdrawn - Currently Amended) A cosmetic process for making up the lips, comprising applying a lip makeup composition to the lips, wherein the lip makeup composition comprises:

at least one cosmetically acceptable organic liquid medium, and

at least one styrene-free film-forming linear block ethylenic polymer,

wherein the lip makeup composition has a resistive index of greater than or equal to 80%,

and further wherein the at least one styrene-free film-forming linear block ethylenic polymer has a polydispersity index of greater than [[2]] or equal to 2.5 and comprises ~~at least one~~ a first block and ~~at least one~~ a second block, wherein the ~~at least one~~ first block and the ~~at least one~~ second block are connected together via ~~at least one~~ an intermediate block comprising at least one constituent monomer of the ~~at least one~~ first block and at least one constituent monomer of the ~~at least one~~ second block, wherein the at least one constituent monomer of the first block differs from the at least one constituent monomer of the second block, said ~~at least one~~ intermediate block is a random copolymer block with a Tg that ranges from the glass transition temperature of the first block to the glass transition temperature of the second block, and the ~~at least one~~ first block is chosen from:

a) a block with a Tg of greater than or equal to 40°C,

b) a block with a Tg of less than or equal to 20°C,

c) a block with a Tg from greater than 20 to less than 40°C,

and the ~~at least one~~ second block is chosen from a category a), b) or c) different from the ~~at least one~~ first block.

144. (Withdrawn - Currently Amended) A cosmetic process for making up the lips, comprising applying a lip makeup composition to the lips wherein the lip makeup composition comprises:

at least one cosmetically acceptable organic liquid medium, and

at least one non-elastomeric film-forming linear block ethylenic polymer,

wherein the lip makeup composition has a resistive index of greater than or equal to 80%

and further wherein the at least one styrene-free film-forming linear block ethylenic polymer has a polydispersity index of greater than [[2]] or equal to 2.5 and comprises ~~at least one~~ a first block and ~~at least one~~ a second block, wherein the ~~at least one~~ first block and the ~~at least one~~ second block are connected together via ~~at least one~~ an intermediate block comprising at least one constituent monomer of the ~~at least one~~ first block and at least one constituent monomer of the ~~at least one~~ second block, wherein the at least one constituent monomer of the first block differs from the at least one constituent monomer of the second block, said ~~at least one~~ intermediate block is a random copolymer block with a Tg that ranges from the glass transition temperature of the first block to the glass transition temperature of the second block, and the ~~at least one~~ first block is chosen from:

a) a block with a Tg of greater than or equal to 40°C,

b) a block with a Tg of less than or equal to 20°C,

c) a block with a Tg from greater than 20 to less than 40°C,

and the ~~at least one~~ second block is chosen from a category a), b) or c) different from the ~~at least one~~ first block.

145. (Withdrawn - Currently Amended) A method for obtaining a lip makeup composition that provides a deposit on the lips that has good resistance, said method comprising including in the lip makeup composition

at least one cosmetically acceptable organic liquid medium, and

at least one styrene-free film-forming linear block ethylenic polymer,

wherein the lip makeup composition has a resistive index of greater than or equal to 80%,

and further wherein the at least one styrene-free film-forming linear block ethylenic polymer has a polydispersity index of greater than [[2]] or equal to 2.5 and comprises ~~at least one~~ a first block and ~~at least one~~ a second block, wherein the ~~at least one~~ first block and the ~~at least one~~ second block are connected together via ~~at least one~~ an intermediate block comprising at least one constituent monomer of the ~~at least one~~ first block and at least one constituent monomer of the ~~at least one~~ second block, wherein the at least one constituent monomer of the first block differs from the at least one constituent monomer of the second block, said ~~at least one~~ intermediate block is a random copolymer block with a Tg that ranges from the glass transition temperature of the first block to the glass transition temperature of the second block, and the ~~at least one~~ first block is chosen from:

a) a block with a Tg of greater than or equal to 40°C,

b) a block with a Tg of less than or equal to 20°C,

c) a block with a Tg from greater than 20 to less than 40°C,

and the ~~at least one~~ second block is chosen from a category a), b) or c) different from the ~~at least one~~ first block.

146. (Withdrawn - Currently Amended) A method for obtaining a lip makeup composition that provides a deposit on the lips that has good resistance, said method comprising including in the lip makeup composition

at least one cosmetically acceptable organic liquid medium, and

at least one non-elastomeric film-forming linear block ethylenic polymer,

wherein the lip makeup composition has a resistive index of greater than or equal to 80%,

and further wherein the at least one styrene-free film-forming linear block ethylenic polymer has a polydispersity index of greater than [[2]] or equal to 2.5 and comprises ~~at least one~~ a first block and ~~at least one~~ a second block, wherein the ~~at least one~~ first block and the ~~at least one~~ second block are connected together via ~~at least one~~ an intermediate block comprising at least one constituent monomer of the ~~at least one~~ first block and at least one constituent monomer of the ~~at least one~~ second block, wherein the at least one constituent monomer of the first block differs from the at least one constituent monomer of the second block, said ~~at least one~~ intermediate block is a random copolymer block with a Tg that ranges from the glass transition temperature of the first block to the glass transition temperature of the second block, and the ~~at least one~~ first block is chosen from:

a) a block with a Tg of greater than or equal to 40°C,

b) a block with a Tg of less than or equal to 20°C,

c) a block with a Tg from greater than 20 to less than 40°C,

and the ~~at least one~~ second block is chosen from a category a), b) or c) different from the ~~at least one~~ first block.

147. (Currently Amended) The lip makeup composition according to Claim 78, wherein the ~~at least one~~ first block and the ~~at least one~~ second block are copolymers derived from monomers chosen from isobornyl (meth)acrylate, isobutyl acrylate and acrylic acid.